

#18/Amoldt E
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C. Moore

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : H. Zhang Art Unit : 2814
Serial No.: 09/362,808 Examiner : S. Rao
Filed : July 28, 1999 Confirmation No. 7320
Title : METHOD OF FABRICATING SEMICONDUCTOR DEVICE

BOX RCE

Commissioner for Patents
Washington, D.C. 20231

AMENDMENT

Sir:

Please amend the above-referenced application as follows.

In the Claims:

Please amend the claims as follows.

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OCT 31 2002

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1. (Amended) A semiconductor device comprising:

E¹
a semiconductor having at least channel, source and
drain regions;
an insulating film formed on said semiconductor;
a gate electrode over the insulating film;
a first interlayer insulating film over said insulating
film and the gate electrode;

CERTIFICATE OF TRANSMISSION BY FACSIMILE

I hereby certify that this correspondence is being transmitted by
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October 31, 2002
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